DuPont[™] Kalrez[®] 8002

For Semiconductor Ash/Strip Applications

Technical Information - March, 2017

Product Description

DuPont[™] Kalrez[®] 8002 perfluoroelastomer parts are a clear product for ash/strip applications. This unfilled product offers excellent plasma-cracking resistance and ultra-low particle generation in oxygen and fluorine-based plasmas versus mineral-filled products. Kalrez[®] 8002 exhibits excellent resistance to dry process chemistry, has good mechanical strength and is well suited for static, low stress/low sealing force and "select" bonded door seal applications. A maximum application temperature of 275°C (527°F) is suggested. Ultrapure post cleaning and packaging is standard for all Kalrez[®] 8002 parts.

Performance Features/Benefits

- Ultra-low particle generation in oxygen and fluorine-based plasmas
- Excellent (low) compression set properties
- Excellent plasma-cracking resistance
- Excellent resistance to dry process chemistry

Suggested Applications

- Gas inlet seals
- Gas orifice seals
- Gas feedthrough seals
- "Select" bonded door seals
- Other static and low stress/low sealing force applications

Typical Physical Properties¹

Color	Clear
Hardness, Shore A (plied slabs) ²	69
Hardness, Shore M (O-ring) ³	76
100% Modulus⁴, MPa (psi)	2.30 (334)
Tensile Strength at Break ⁴ , MPa (psi)	23.10 (3350)
Elongation at Break ⁴ , %	256
Comp. Set ⁵ , %, 70 hr. at 204 °C (400 °F)	12
Max. Application Temperature ⁶ , °C (°F)	275 (527)

¹ Not to be used for specification purposes

² JIS 6253 test method (plied slab test specimens)

³ ASTM D2240 and ASTM D1414 (AS568 K214 O-ring test specimens)

⁴ JIS 6251 test method (dumbbell test specimens)

⁵ ASTM D395B and ASTM D1414 (AS568 K214 O-ring test specimens)
⁶ DuPont proprietary test method

Fabs Choose DuPont™ Kalrez® 8002 for Improved Performance

Kalrez® 8002 has been reported to significantly improve wafer production in a variety of semiconductor ash process applications where oxygen and fluorinated plasmas are used.

Case Report #7737 — Kalrez[®] 8002 Improved Wafer Production Over 5x versus Incumbent Perfluoroelastomer

- Process Type: Ash
- Process chemistry: O₂, CF₄
- Process Temperature: ~80C
- Cleaning chemistry: N/A
- Incumbent Performance: Perfluoroelastomer failed after 270 RF hours due to cracking and vacuum leakage.



Case Report #4536 — Kalrez[®] 8002 Improved Wafer Production Over 50% versus Incumbent Perfluoroelastomer

- Process Type: Ash top/bottom plasma tube seals
- Process chemistry: O₂, CF₄
- Process Temperature: 80-150C
- Cleaning chemistry: N/A
- Incumbent Performance: Perfluoroelastomer failed due to erosion and excessive particle generation after 6 months

Competitive FFKM A11 and Kalrez® 8002 after comparable life cycles in the same process

Competitive FFKM A11



2mm



2mm

Visit us at kalrez.dupont.com or vespel.dupont.com

Contact DuPont at the following regional locations:

North America	Latin America	Europe, Middle East, Africa
800-222-8377	+0800 17 17 15	+41 22 717 51 11
Greater China	ASEAN	Japan
+86-400-8851-888	+65-6586-3688	+81-2-5521-8484

The information provided in this data sheet corresponds to DuPont knowledge on the subject at the date of its publication. This information may be subject to revision as new knowledge and experience becomes available. The data provided fall within the normal range of product properties and relate only to the specific material designated; these data may not be valid for such material used in combination with any other materials, additives or pigments or in any process, unless expressly indicated otherwise.

The data provided should not be used to establish specification limits or used alone as the basis of design; they are not intended to substitute for any testing you may need to conduct to determine for yourself the suitability of a specific material for your particular purposes. Since DuPont cannot anticipate all variations in actual end-use and disposal conditions, DuPont does not guarantee results, makes no warranties and assumes no liability in connection with any use of this information. All such information is given and accepted at the buyer's risk. It is intended for use by persons having technical skill, at their own discretion and risk. Nothing in this publication is to be considered as a license to operate under or a recommendation to infringe any patent.

CAUTION: Do not use DuPont materials in medical applications involving implantation in the human body or contact with internal body fluids or tissues unless the material has been provided from DuPont under a written contract that is consistent with DuPont policy regarding medical applications and expressly acknowledges the contemplated use. For further information, please contact your DuPont representative. You may also request a copy of DuPont PÓLICY Regarding Medical Applications H-50103-5 and DuPont CAUTION Regarding Medical Applications H-50102-5.

Copyright © DuPont. The DuPont Oval Logo, DuPont[™], The miracles of science[™], Kalrez[®] is a trademark or registered trademark of E.I. du Pont de Nemours and Company or its affiliates. All rights reserved.

(03/17) Reference No. KZE-A10024-00-L0317

